AOS Semiconductor
Product Reliability Report

AOZ1328DI, rev A

Plastic Encapsulated Device

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This AOS product reliability report summarizes the qualification results for AOZ1328DI in DFN3x3_12L package. Accelerated environmental tests are performed on a specific sample size and samples are electrically tested before and after each time point. Review of final electrical test results confirm that AOZ1328DI pass the AOS quality and reliability requirements. The released products will be categorized by its process family and routinely monitored for continuous improvement of product quality.

I. Reliability Stress Test Summary and Results

Test Item	Test Condition	Time Point	Total Sample Size	Number of Failures	Reference Standard
HTOL	T_J = 125°C, V_{IN} = V_{IN} max	168 / 500 hours	80 pcs	0	JESD22-A108
Preconditioning (Note A)	T_A = 85°C, RH = 85% + 3 cycle reflow @ 260°C (MSL 1)	168hours	622 pcs	0	JESD22-A113
HAST	T_A = 130°C, RH = 85%, P = 33.3psia, V_{IN} = V_{IN} max	96 hours	80 pcs	0	JESD22-A110
Autoclave	T_A = 121°C, RH = 100%, P = 29.7psia	96 hours	80 pcs	0	JESD22-A102
Temperature Cycle	T_A = -65°C to 150°C, air to air	250/500/ 1000cycles	231 pcs	0	JESD22-A104
HTSL	T_A = 150°C	1000 hours	231 pcs	0	JESD22-A103

Note: The reliability data presents total of available generic data up to the published date.
Note A: MSL (Moisture Sensitivity Level) 1 based on J-STD-020

II. Reliability Evaluation

Taking the result of HTOL AOZ1328DI & AOZ1327DI Lots the total device stress time

FIT rate (per billion): 20 FIT
MTTF = 50 million years

The presentation of FIT rate for the individual product reliability is restricted by the actual burn-in sample size. Failure Rate Determination is based on JEDEC Standard JESD 85. FIT means one failure per billion hours.

Failure Rate = $Chi^2 \times 10^9$ **/** **[**2 (N) (H) (Af)**]** **=** 20
MTTF = 10^9 / FIT = 50 million years

Chi² = Chi Squared Distribution, determined by the number of failures and confidence interval
N = Total Number of units from burn-in tests
H = Duration of burn-in testing
Af = Acceleration Factor from Test to Use Conditions (Ea = 0.7eV and T_{use} = 55°C)
Acceleration Factor [**Af**] = **Exp** [Ea / **k** ($1/T_J$ u – $1/T_J$ s)]
Acceleration Factor ratio list:

	55 deg C	70 deg C	85 deg C	100 deg C	115 deg C	125 deg C
Af	77	26	9.8	3.9	1.7	1

T_J s = Stressed junction temperature in degree (Kelvin), K = C + 273.16
T_J u =The use junction temperature in degree (Kelvin), K = C + 273.16
k = Boltzmann's constant, 8.617164 X 10^{-5}eV / K

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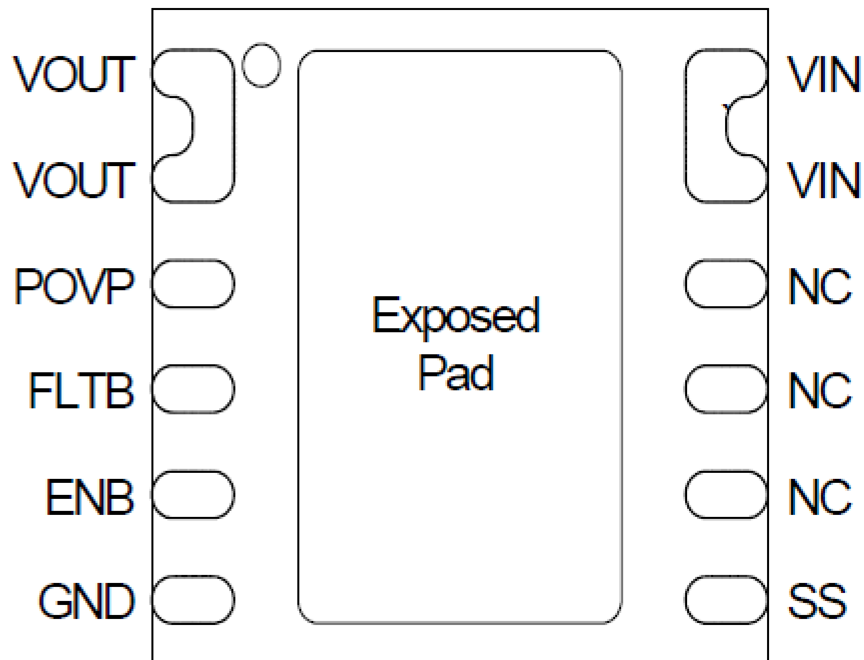
III. ESD and Latch Up Test Results

Test	Test Conditions	Total Sample Size	Number of Failures	Reference Standard
Electrostatic Discharge Human Body Model	T_A = 25°C, +/-2kV	3	0	JESD-A114
Electrostatic Discharge Charged Device Model	T_A = 25°C, +/-1kV	3	0	JESD-C101
Latch Up	T_A = 25°C, +/-100mA, 1.5x OV	6	0	JESD78
Latch Up	T_A = 85°C, +/-100mA, 1.5x OV	6	0	JESD78

(1) ATE results are used to determine PASS/FAIL. Parametric shift<10%.



3mm x 3mm DFN-12L

(Top Transparent View)